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Attorney Docket Number

10/750,042 December 30, 2003

Wang Yueh

1795

Amanda C. Walke

42P18259

Examine Initials*	Cite	Document Number Number - Kind Code² (if known)	Publication Date Issue Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
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		WO 2005/066715 A2	07-21-2005	Intel Corporation	

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Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.

T2

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